

## A DIRECT PREPARATION OF SOME PENTAFLUOROPHENYL-CONTAINING SILANES

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(Received January 9th, 1968)

### SUMMARY

The reaction of pentafluorobromobenzene with both tetraethoxysilane and tetrachlorosilane, by a modified Grignard method, leads to the formation of compounds of the type  $(C_6F_5)_nSiX_{4-n}$  where  $X = OC_2H_5$  and Cl and  $n = 1-4$ .

These compounds have been characterized by physical methods, elemental analysis, interconversion and the preparation of derivatives.

### INTRODUCTION

Normally, using a Grignard or lithium synthesis, it is possible to substitute halo- and alkoxy-silanes with organic groups (R). Usually a mixture of variously substituted silanes is obtained and it appears that the Grignard synthesis of organohalosilanes can be treated as a series of successive reactions of the type  $AX_4 + RY \rightarrow AX_mR_n + nXY^1$ . The lithium synthesis is considered to be very similar to that of the Grignard reaction, though the higher reactivity of the organolithium reagent, which is one of its main advantages, leads to more highly substituted silanes.

However the reaction of pentafluorophenylmagnesium bromide<sup>2,3</sup> or pentafluorophenyllithium<sup>3</sup> with tetrachlorosilane has been shown to yield only the fully substituted tetrakis(pentafluorophenyl)silane in low yield. Irrespective of the mode of addition or the relative amounts of reagents used, the partially substituted products  $(C_6F_5)_nSiCl_{4-n}$  could not be obtained directly from these reactions. Recently it has been reported<sup>4</sup> that methyl(pentafluorophenyl)diethoxysilane and bis(pentafluorophenyl)diethoxysilane have been synthesized by the Grignard method though no details of the experimental procedure were given.

We would like to report here a direct synthesis of compounds of the type  $(C_6F_5)_nSiX_{4-n}$  where  $X = OC_2H_5$  and Cl and  $n = 1-4$  using a Grignard synthesis.

### RESULTS AND DISCUSSION

Tamborski and co-workers<sup>5</sup> explained the formation of the tetrakis(pentafluorophenyl)silane on the basis that once one pentafluorophenyl-group is introduced the reactivity of the remaining chlorine atoms attached to silicon is enhanced and further replacement is rapid to give the fully substituted silane. A further complication which accounts for the low yield, appears to be that tetrachlorosilane catalyses the

decomposition of the Grignard or lithium reagent (prepared from pentafluorobromobenzene) to give polymeric sideproducts.

It has been shown<sup>6</sup> that tetraethoxysilane is less reactive than tetrachlorosilane towards Grignard reagents and that the resulting substituted ethoxysilanes have similar properties to the more reactive substituted chlorosilanes. It was thought that the Grignard reagent with tetraethoxysilane might yield the desired partially substituted silanes. The Grignard reagent was preferred to the more reactive lithium reagent which, we considered, would lead preferentially to the formation of the tetra-substituted silane.

The reaction of pentafluorophenylmagnesium bromide and tetraethoxysilane was examined in detail. The normal procedure of adding the preformed Grignard reagent, in a suitable solvent, to tetraethoxysilane gave, as the only product isolated, the known tetrakis(pentafluorophenyl)silane in low yield. It was thought that this problem of tetrasubstitution and the formation of side products might be due to high local concentrations of Grignard reagent which, even with high speed stirring, must occur at the point of addition. To overcome these high concentrations we proposed to modify the Grignard synthesis and attempt to form the Grignard reagent *in situ* using tetraethoxysilane as both solvent and reactant. No reaction could be induced between pentafluorobromobenzene, tetraethoxysilane and magnesium turnings when mixed together. Even the addition of ethylbromide failed to promote any discernible reaction. However upon adding diethyl ether dropwise a "critical concentration" was reached and a vigorous reaction observed. Examination of this reaction mixture by gas chromatography showed, apart from starting materials, two major components, (pentafluorophenyl)triethoxysilane and bis(pentafluorophenyl)diethoxysilane, and two trace components thought to be the tri- and tetra-substituted silanes.

These ethoxysilanes were characterized by molecular weight determination (mass spectrometry and vapour pressure osmometry) and elemental analysis. The infrared spectra showed the characteristic bands associated with pentafluorophenyl-<sup>7,3</sup> and ethoxy-<sup>8</sup> groups. The NMR spectra were also consistent with the proposed structures.

Further evidence for these structures was obtained as follows: Examination of the reaction of methylmagnesium iodide and (pentafluorophenyl)triethoxysilane showed that, using excess of the Grignard reagent, the fully substituted silane, trimethyl(pentafluorophenyl)silane was formed in more than 90% yield. This was identical to the product from trimethylchlorosilane and pentafluorophenylmagnesium bromide in diethyl ether<sup>9</sup>. Using equimolar ratios of methylmagnesium iodide and the triethoxysilane afforded methyl(pentafluorophenyl)diethoxysilane and dimethyl(pentafluorophenyl)ethoxysilane in the ratio 2:1 with a trace of trimethyl(pentafluorophenyl)silane. These structures were confirmed by proton NMR spectroscopy. With bis(pentafluorophenyl)diethoxysilane, methylmagnesium iodide gave dimethylbis(pentafluorophenyl)silane in high yield. Both the ethoxysilanes were smoothly converted into the chlorosilanes by acetyl chloride though reaction of aqueous ethanolic HF resulted, not in the formation of the fluorosilanes, but in complete and rapid cleavage of the pentafluorophenyl groups.

This modified Grignard synthesis was then applied to tetrachlorosilane. Diethyl ether was added dropwise to a mixture of pentafluorobromobenzene, tetrachlorosilane and magnesium turnings until a reaction was observed. Examination





